

JC868 U.S. PTO
10/053622

01/24/02

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U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10053622	01/24/2002	430		1752	
**APPLICANTS: Tachikawa Toshikazu; Kaneko Fumitake; Kubota Naotaka; Miyairi Miwa; Hirosaki Takako; Endo Koutaro;					
**CONTINUING DATA VERIFIED: THIS APPLICATION IS A CIP OF 09/638,872 08/15/2000, 70-T. 6,400,829 KVA					
** FOREIGN APPLICATIONS VERIFIED: JAPAN 11-234688 08/20/1999 RA					
PG-PUB		DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>	
Foreign priority claimed		<input checked="" type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO	
35 USC 119 conditions met		<input checked="" type="checkbox"/> yes <input type="checkbox"/> no		2002-0069	
Verified and Acknowledged Examiners's initials		RA			
TITLE : Negative-working photoresist composition					

U.S. DEPT. OF COMM./PAT. & TM-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		Assistant Examiner	CLAIMS ALLOWED	
			Total Claims	Print Claim for O.G.
ISSUE FEE		Primary Examiner	DRAWING	
Amount Due	Date Paid		Sheets Drwg.	Figs. Drwg.
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE	Application Examiner	
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